Kamal Lochan Panda

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Career Objective:

To utilize my skills and abilities that offers professional growth while being resourceful, innovative and flexible.

Brief Profile:

Highest degree : MSc (Physics), MCA, PhD(Continue)

Date of birth : 2nd July 1982

Sex : Male
Caste : General
Religion : Hindu
Nationality : Indian

Summary:

• Ability to plan, organize and manage resources for organizational development.

- •Dedicated problem solver, who thinks logically, values creativity and cares about people to excel in their key performance areas.
- Effective leader, exhibiting the ability to achieve organizational goals.
- Enthusiastic, eager to learn, meet new challenges and assimilate new concepts.
- An accomplished motivator exhibiting high degree of ethics, governance and confidence driven by a personal commitment to team excellence

• Educational Qualification:

Exams Passed	School/ College	Board/ University	Year Of Passing	% Of Marks	Class/ Division
10 th	G.D.HighSchool, Cuttack	B.S.E. Orissa	1997	66.9	First
ISc.	Banki College, Banki, Cuttack	C.H.S.E Orissa	1999	62.3	First
BSc (Physics).	Banki College, Banki,Cuttack	Utkal University , Orissa	2002	60.0	First
MSc (Physics).	Khallikote Autonomous College	Berhampur University Orissa	2004	78.2	First
MCA	Rourkela Institute of Technology	BPUT, Orissa	2010	66.6/ 7.16 cgpa	First

Achievement:

- Presented and participated in a National level Seminar Talk at N.I.T. Rourkela, Odisha.
- Participated in a Workshop on Research Methodology at KIIT University, Odisha.

Experience:

- Two years working as a Guest lecturer in Physics in VHJ Mahavidyalaya, Nikirai, Kendrapara from 2004 to 2006.
- Two years working as a Lecturer in physics in Tulasi Women's College, Kendrapara from 2010 to 2012.
- Worked as Professor at UNITECH College, Nayagarh.

Research:

Pursuing PhD in Physics under KIIT University since 2012 onwards.

Publications:

- Annealing treatments role of SiO2 buffer layer on photoluminance and charge storage mechanism in Sillicon-rich SiNx:H films.
- Ge nanocrystals embedded in SiNx dielectric films with HfO2/SiO2 stack tunnel dielectrics by low energy ion beam synthesis.

Conference:

- 1. National Conference i.e. Confluence 2k4 at NIT, Rourkela in 2004
- 3. National Conference named "Odisha Bigyan Congress" at Institute of Physics, DAE, and Bhubaneswar in 2013.
- 4. National Conference named Regional Science Congress at KIIT University, Bhubaneswar.

Language:

MS Office

Hobbies:

Plantation, Playing Chess & Carom, Reading newspaper.

Corresponding Address:

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